

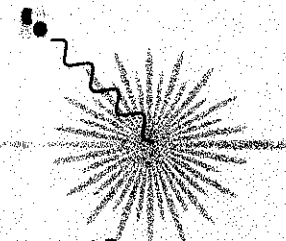
ADRIATICO RESEARCH CONFERENCE on
LASERS IN SURFACE SCIENCE

11-15 September 2000

Miramare - Trieste, Italy

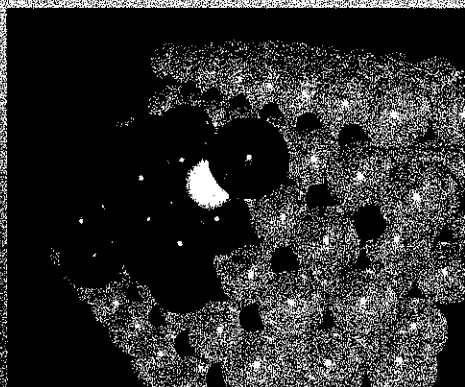
*Nonthermal UV-laser induced diffusion and desorption
processes of CO on nano-sized Pd aggregates
adsorbed on an epitaxial Al₂O₃-support*

K. Al-Shamery & A. Wille
Carl Von Ossietzky Universitat, Oldenburg - Germany



Nonthermal UV-laser induced diffusion and desorption processes of CO on nano-sized Pd aggregates adsorbed on an epitaxial Al₂O₃-support

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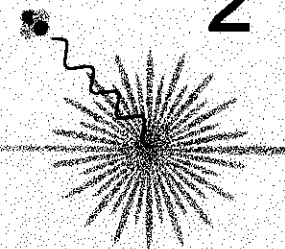


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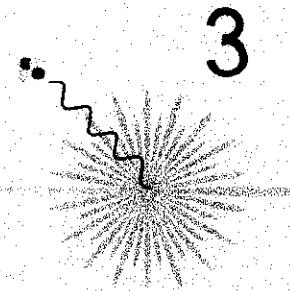
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- 2. The model catalyst system CO/Pd/Al₂O₃/NiAl(110)**
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- 5. Summary**

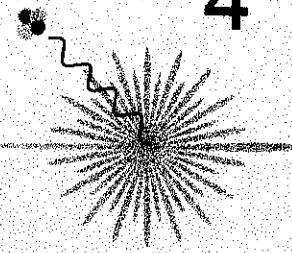
Motivation



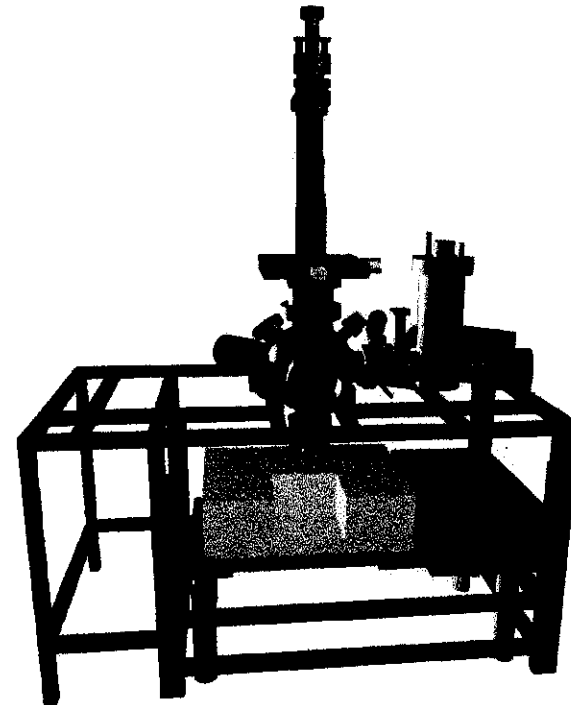
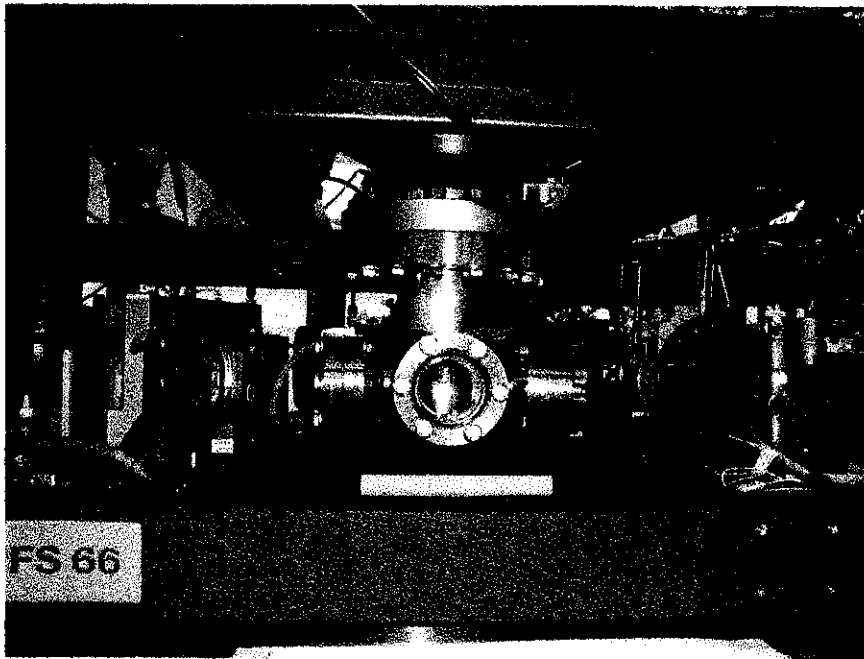
- ⇒ Nanostructured metal particles important for many catalytic reactions
- ⇒ Closing of the „material gap“
- ⇒ Size and morphology dependence of photodissociation and photodesorption of methane on Pd/Al₂O₃/NiAl(110)
- ⇒ Variation of aggregate size as tool to control surface photo reactions
- ⇒ Better understanding of the relevant mechanisms by probing CO on Pd/Al₂O₃/NiAl(110)

Experimental setup

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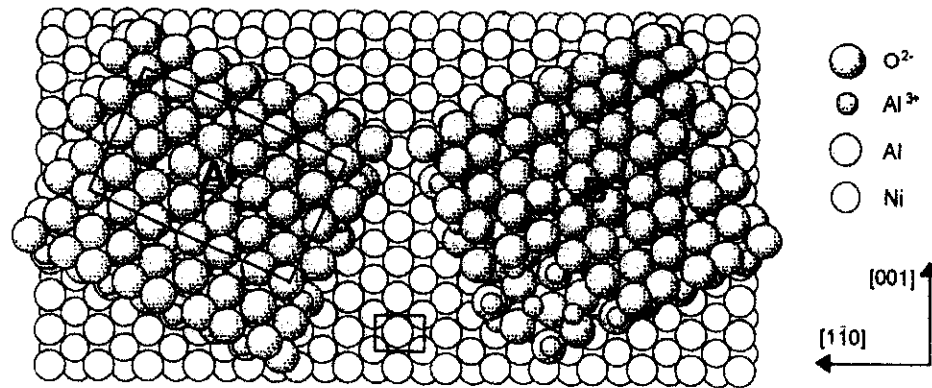
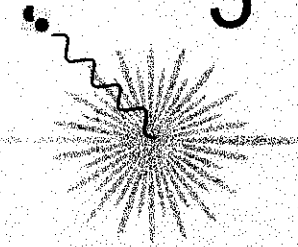


- Standard ultra high vacuum chamber
- Spectroscopic utilities: purged FTIR system, LEED, Auger
- Laser system: Nd/YAG laser, 10 pulses per second, 0.3 mJ/cm^2 at 355 nm



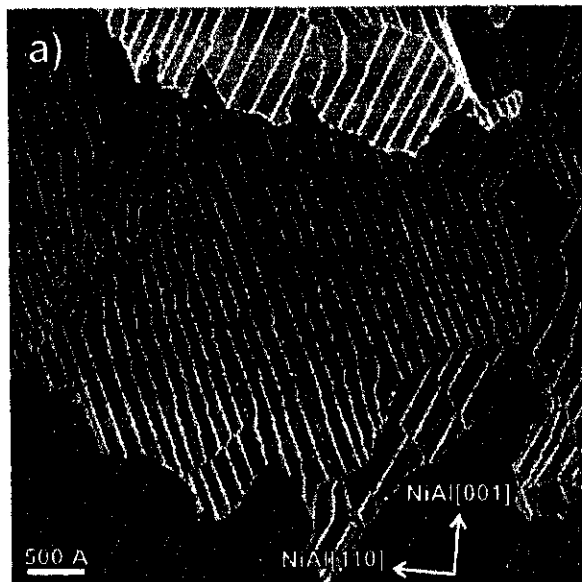
The alumina film

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Structure model of $\text{Al}_2\text{O}_3/\text{NiAl}(110)$, derived from a distorted g- Al_2O_3 structure

[J. Libuda, M. Bäumer, H.-J. Freund, *J. Vac. Sci. Technol. A* 12 (1994) 2259]



STM images of the alumina film:

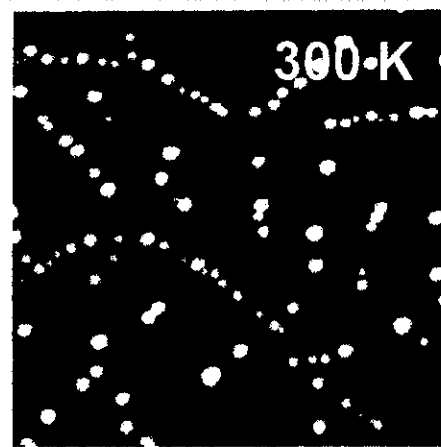
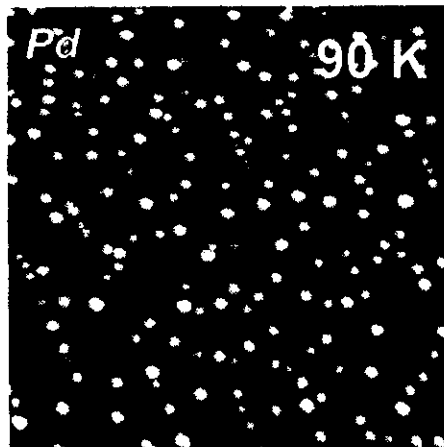
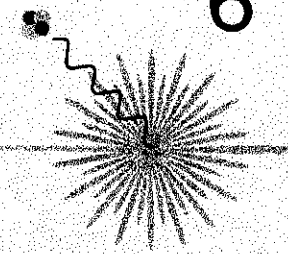
a) STM image of the thin alumina film grown on NiAl(110) (CCT, 5000 Å²)

b) Close-up showing the various domain boundaries in more detail (CCT, 775 Å x 400 Å); (A-A), (B-B): antiphase domain boundaries, (A-B): reflection domain boundaries

Frank, to be published

Pd deposition at 300 K and 90 K

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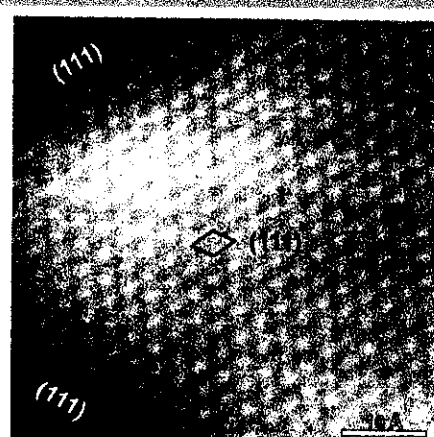
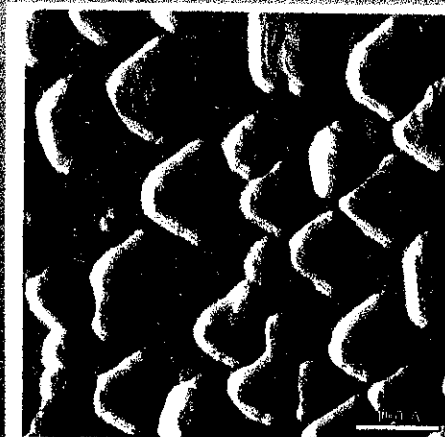


STM images taken after deposition of small amounts of Pd (CCT, 1000 Å²)

Left: amorphous aggregates

Right: crystalline aggregates

[M. Frank, M. Bäumer, to be published]

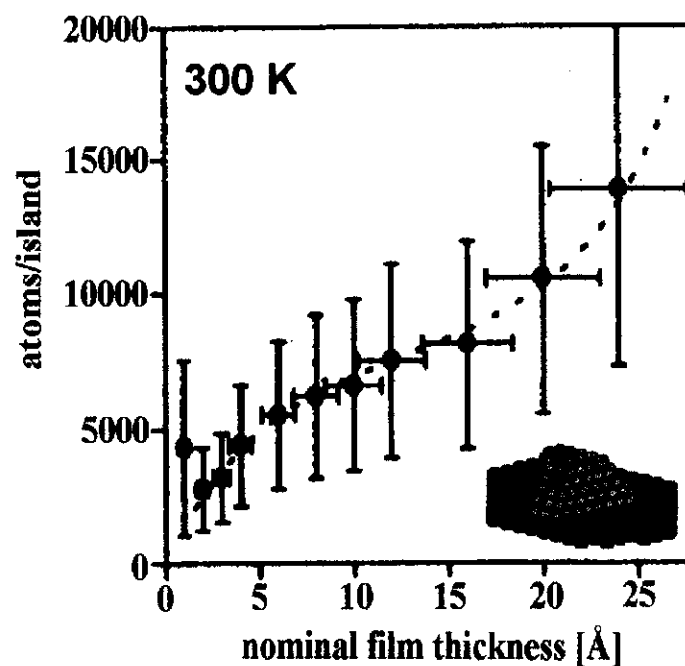
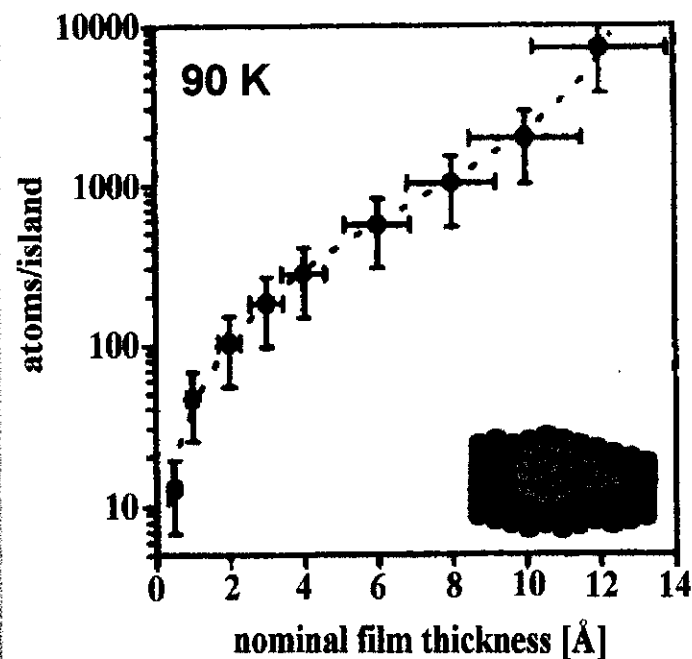
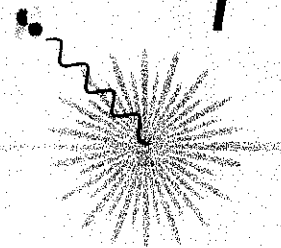


Left: Differentiated STM image of crystalline Pd aggregates grown at 300 K (CCT, 500 Å²)

Right: Close-up showing an aggregate with distinct crystalline faces (111) and (110)

Average sizes of Pd aggregates

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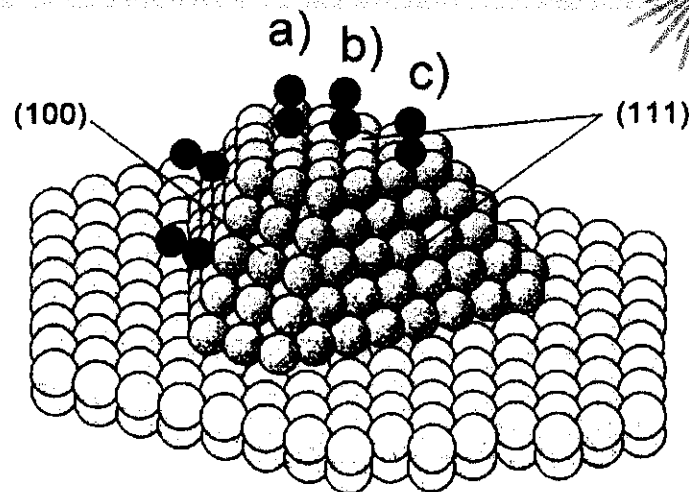
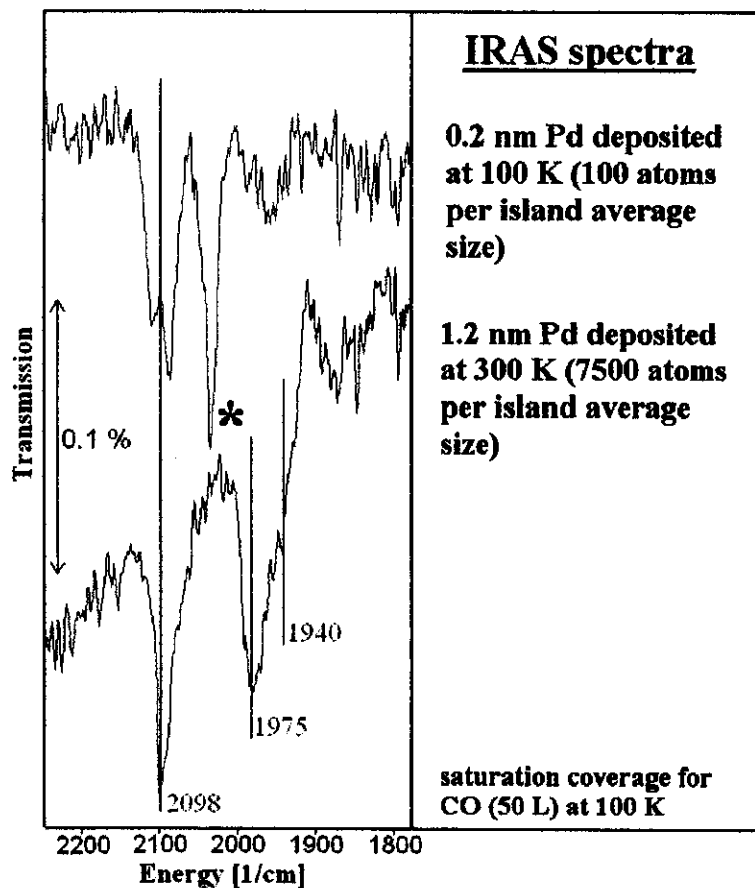


Average number of atoms per island determined by LEED spot-profile analysis

Source: *Journal of Chemical Physics*, 1997, Vol. 106, No. 12, pp. 5041-5046

CO on Pd/Al₂O₃/NiAl(110)

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Schematic model of a crystalline Pd particle and the specific adsorption sites of CO:

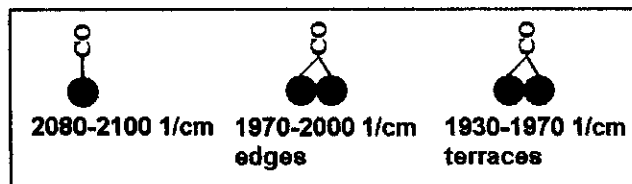
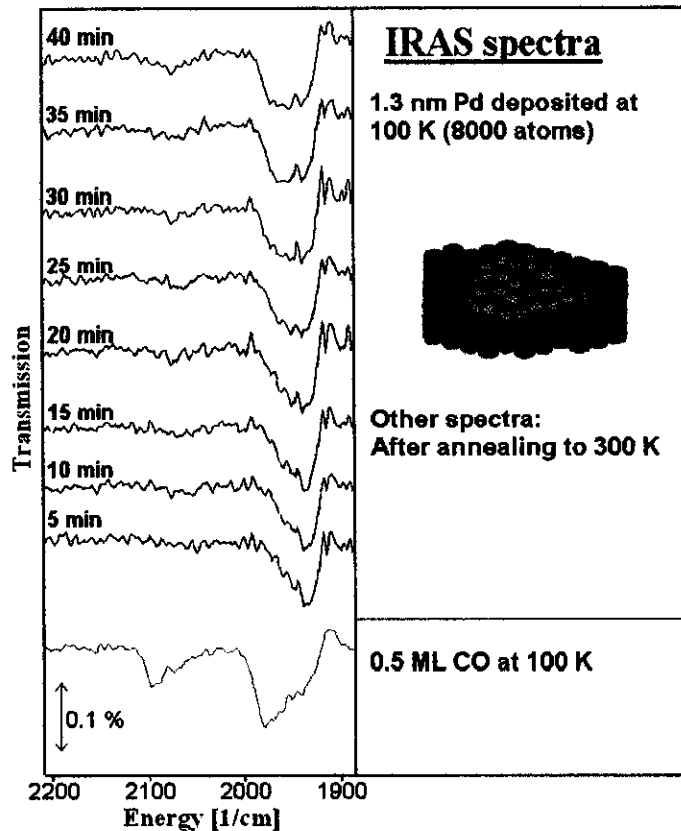
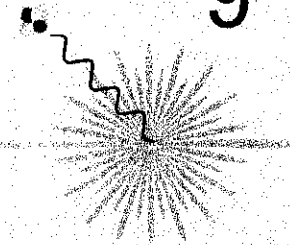
a) Terminal bonded CO on terraces: 2080-2100 cm⁻¹

b) Bridge bonded CO on edges: 2050-2070 cm⁻¹

c) Bridge bonded CO on corners: 2020-2040 cm⁻¹

Annealing and cooling experiment

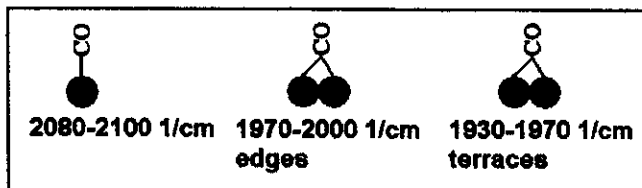
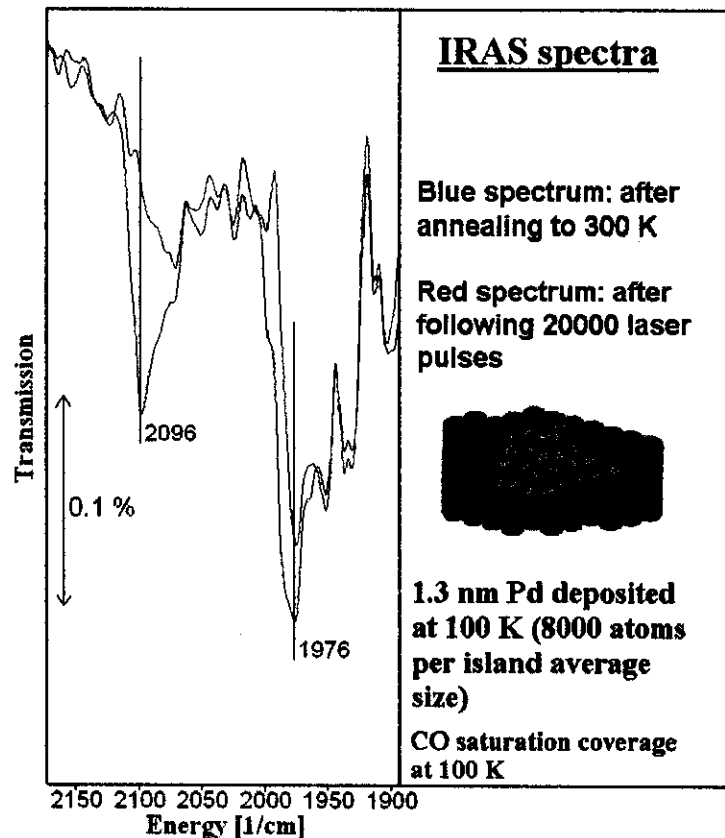
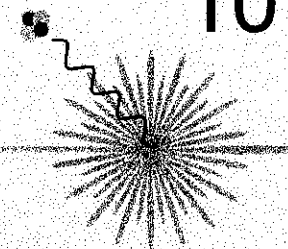
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- ⇒ Terminal bonded CO species and bridge bonded species on the edges disappear by annealing to 300 K.
- ⇒ Slight reoccupation of terminal bonded species during cooling period
- ⇒ Partially reoccupation of the bridge bonded adsorption site on the edges
- ⇒ No changes at 100 K

Annealing experiments

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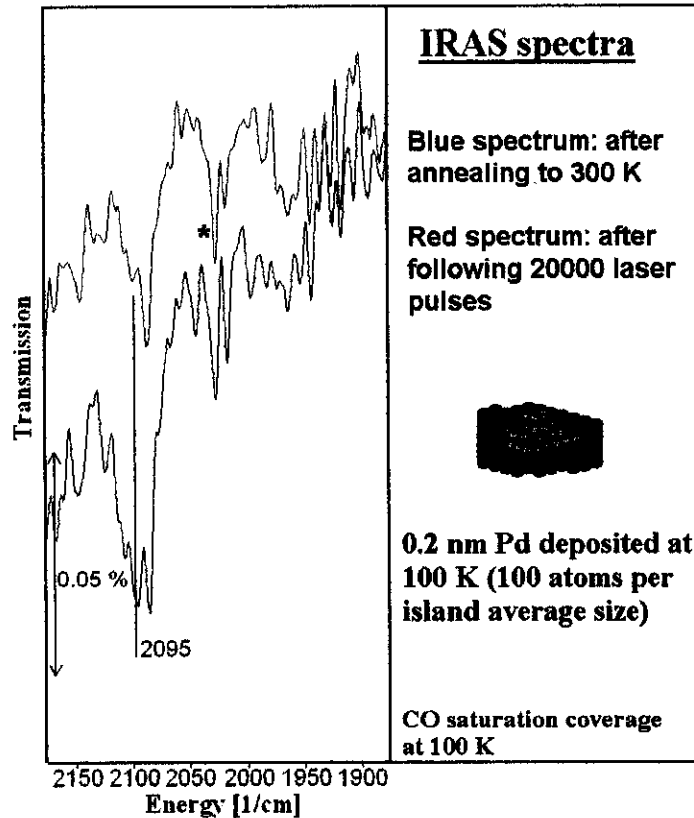
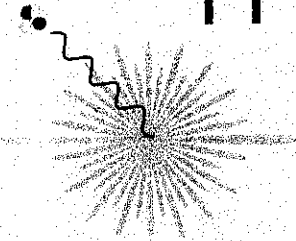
8000 atoms per island

(amorphous)

- ⇒ Obvious increase in band intensity of terminal bonded CO caused by laser exposure
- ⇒ Small increase in band intensity of bridge bonded CO species on the edges

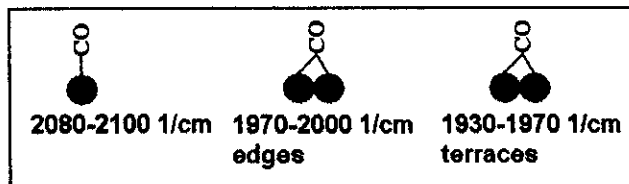
Annealing experiments

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0.2 nm Pd deposited at
100 K (100 atoms per
island average size)

CO saturation coverage
at 100 K

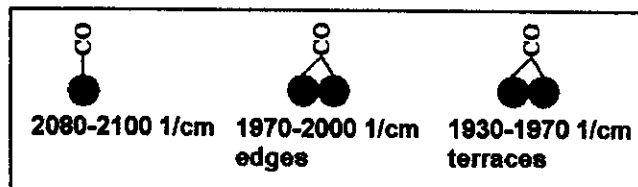
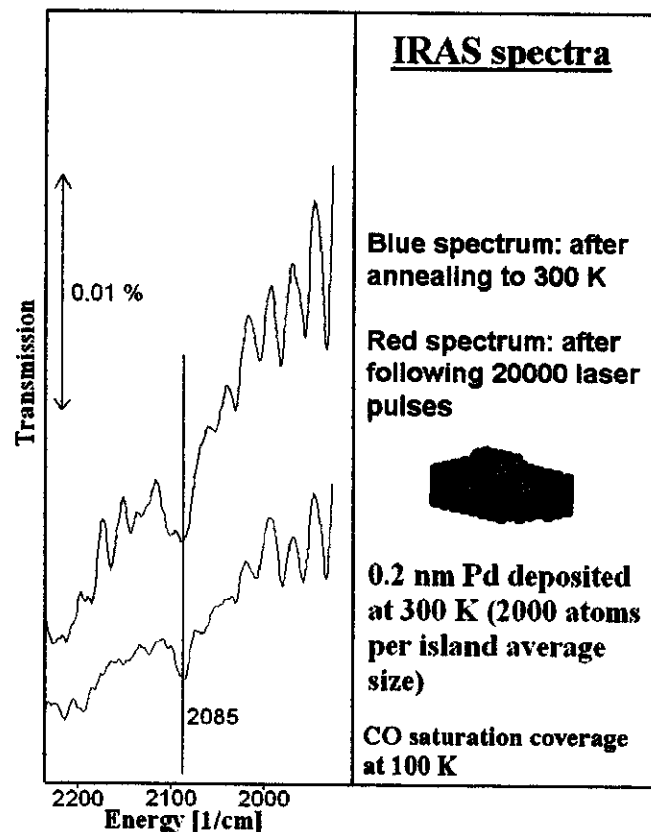
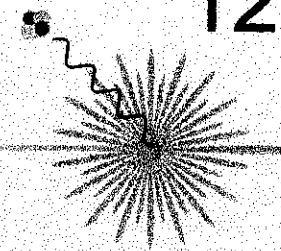


100 atoms per island
(amorphous)

⇒ Obvious increase in band intensity
of terminal bonded CO caused by
laser exposure

Adsorption bands of CO not specified
in literature for Pd islands at 2030 K

Annealing experiments



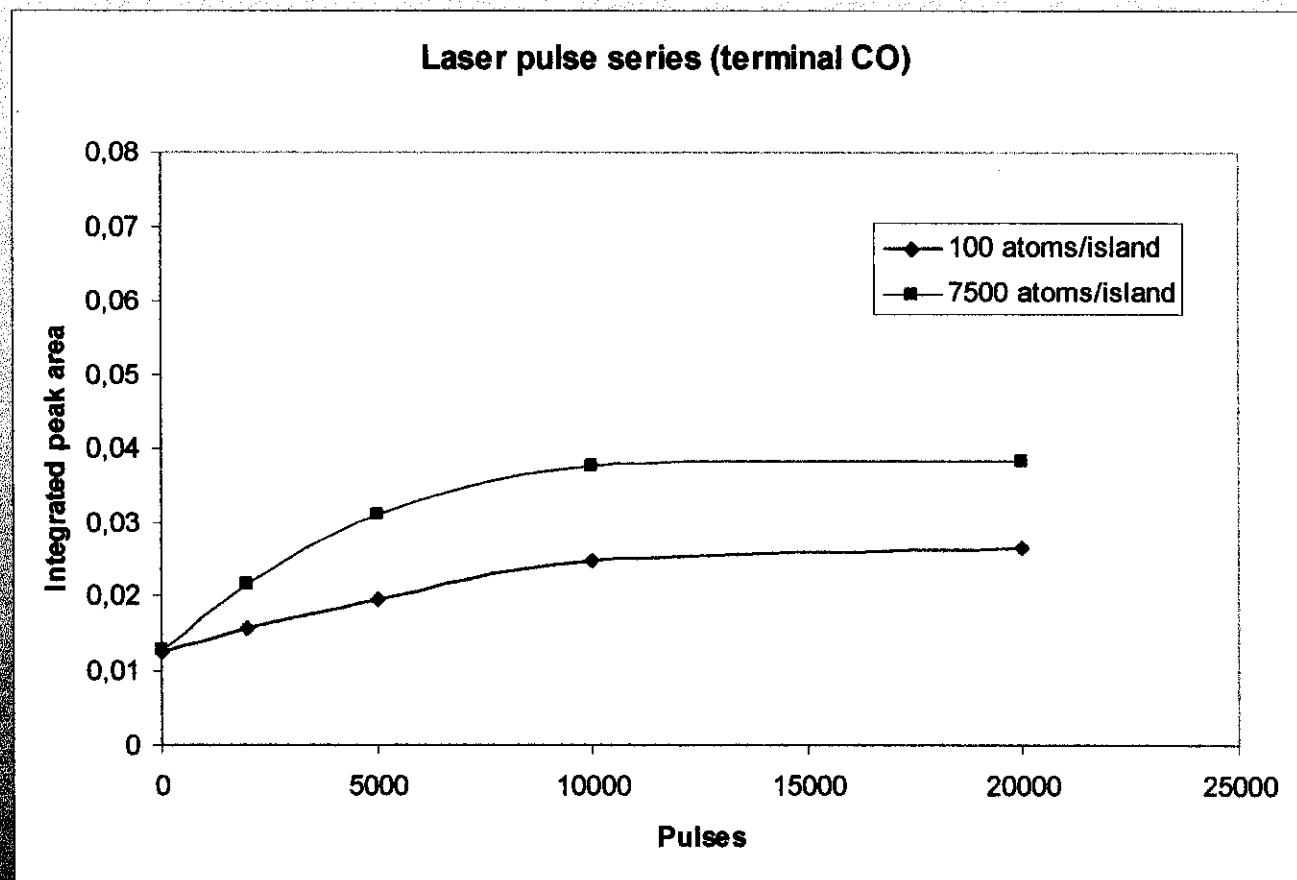
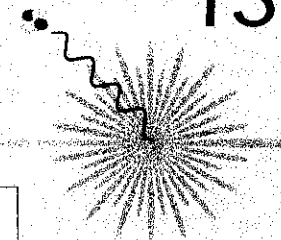
2000 atoms per island

(crystalline)

⇒ Obvious increase in band intensity of terminal bonded CO caused by laser exposure

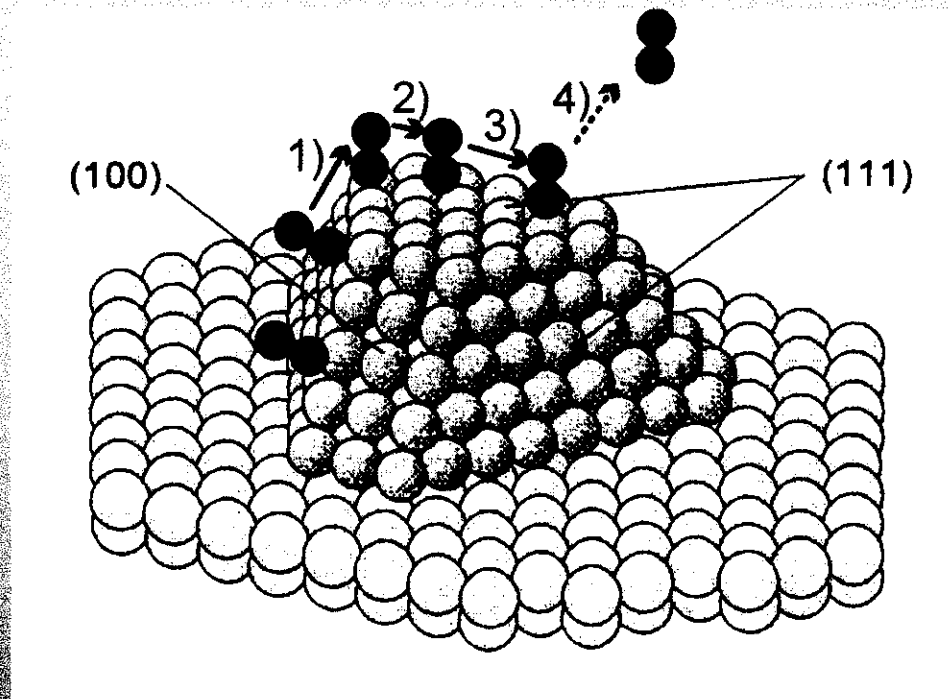
Laser pulse series

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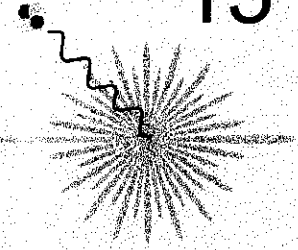
terminal CO bonded

Possible diffusion mechanism



1) CO diffusion from non-infrared active adsorption sites on the particle facets onto infrared active on-top sites

2) Diffusion from the non-infrared active sites to the infrared active sites on the particle facets

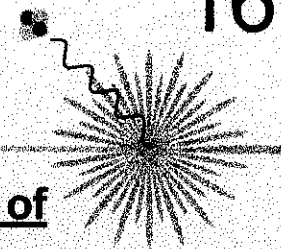


Effects of laser exposure:

- ⇒ **Obvious increase in band intensity of terminal bonded CO**
- ⇒ **Increase in band intensity of bridge bonded CO on the edges**
- ⇒ **Size dependent effects by laser exposure**
- ⇒ **Suggestion of a laser induced diffusion mechanism**

Acknowledgement

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M. Frank

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